

**IN THE SPECIFICATION:**

A Substitute Specification was forwarded by a Preliminary Amendment that was filed on December 30, 2004. Please replace the paragraph at page 14 of the Substitute Specification, line 14 to page 15, line 1 with the following rewritten paragraph:

ZPN 1100 (made by Nippon Zeon Co., Ltd.) was applied using a spin coating method onto an upper surface of the color-converting layers, and then patterning was carried out using a photolithography method, thus forming a stress-relieving layer having a reverse tapered shape provided at edges of the color-converting layers. The thickness of the stress-relieving layer was 5  $\mu\text{m}$  from the surface of the color-converting layers. Next, leaving only walls of the stress-relieving layer, an upper surface of the stress-relieving layer and upper surfaces of the color-converting layers were coated with an OFPR 8000 photoresist (made by Tokyo Ohka Kogyo Co., Ltd.). A Benefix VL visible light-curable resin (made by Ardel, refractive index 1.48) was further coated thereon, and then irradiation with visible light was carried out; the OFPR 8000 was then removed using a Stripping Solution ~~stripping liquid~~ 104 ("Stripping Solution 104" is the name a product made by Tokyo Ohka Kogyo Co., Ltd.), whereby a stress-relieving layer 8 in which only the walls of the ZPN 1100 were coated with Benefix VL was formed.